Special Issue

Emerging Trends in Embedded Systems and Applications for Intelligent Process Control

Message from the Guest Editors

For this Special Issue, authors are encouraged to submit their original research in any of the following or related areas:

- Intelligent control systems
- Embedded intelligence and machine learning
- Software/hardware co-design and optimization
- Energy efficient architecture design
- Micro- and nano-systems
- Run-time power optimization
- Wireless communication and tracking
- Optimization algorithms

Guest Editors

Dr. Charalampos S. Kouzinopoulos

Information Technologies Institute (ITI)/Centre of Research and Technology Hellas, Thessaloniki, Greece

Prof. Dr. Konstantinos Margaritis

Department of Applied Informatics, Unversity of Macedonia, 156 Egnatia Str., 54636 Thessaloniki, Greece

Deadline for manuscript submissions

closed (28 February 2024)

Processes

mdpi.com/si/168979

mdpi.com/journal/
processes

Processes

an Open Access Journal
by MDPI

Impact Factor 2.8
CiteScore 5.5

mdpi.com/journal/
processes

About the Journal

Message from the Editor-in-Chief

You are invited to contribute either a research article or a comprehensive review for consideration and publication in *Processes* (ISSN 2227-9717). *Processes* is published in open access format – research articles, reviews, and other content are released on the internet immediately after acceptance. The scientific community and the general public have unlimited, free access to the content. As an open access journal, *Processes* is supported by the authors and their institutes through the payment of article processing charges (APCs) for accepted papers. We would be pleased to welcome you as one of our authors.

Editor-in-Chief

Prof. Dr. Giancarlo Cravotto
Department of Drug Science and Technology, University of Turin, Via P. Giuria 9, 10125 Turin, Italy

Author Benefits

Open Access:
free for readers, with article processing charges (APC) paid by authors or their institutions.

High Visibility:
indexed within Scopus, SCIE (Web of Science), Ei Compendex, Inspec, AGRIS, and other databases.

Journal Rank:
CiteScore - Q2 (Chemical Engineering (miscellaneous))